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FORM PTO-1449 U.S. Department of Commence Patent and Trademark Office	Docket No. (Optional) CIT1270-1	Serial No.: 09/905,157	
MAR 0 8 2002	Applicant(s): Lewis, et al.		
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EXAMINER Exil Min	DATE CONSIDERED 10/9/02

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FORM PTO-1449 U.S. Department of Commerce Patent and Trademark Office	Docket No. (Optional) CIT1270-1	Serial No.: 09/905,157	
	Applicant(s): Lewis, et al.		
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